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THz Waveplate based on Laser Processed Silicon Grating

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Waveplates:

- Waveplates, or phase retarders, are the essential devices for manipulating and controlling the polarization state of EM radiation.
- Waveplates introduce a controlled phase delay between two orthogonal polarization components, enabling modulation of EM wave properties via change of the polarization state.

Birefringence:

- Birefringence is an optical phenomenon that occurs when a light passes through a specific material experiences different refractive indices for different polarizations of light, where each polarization component propagates with a different speed.
- Eg: Liquid crystals, Crystalline quartz, and LiNbO_3
- These natural birefringence materials are very limited in the THz regime due to the low birefringence, large loss, bulk in size, and high price.

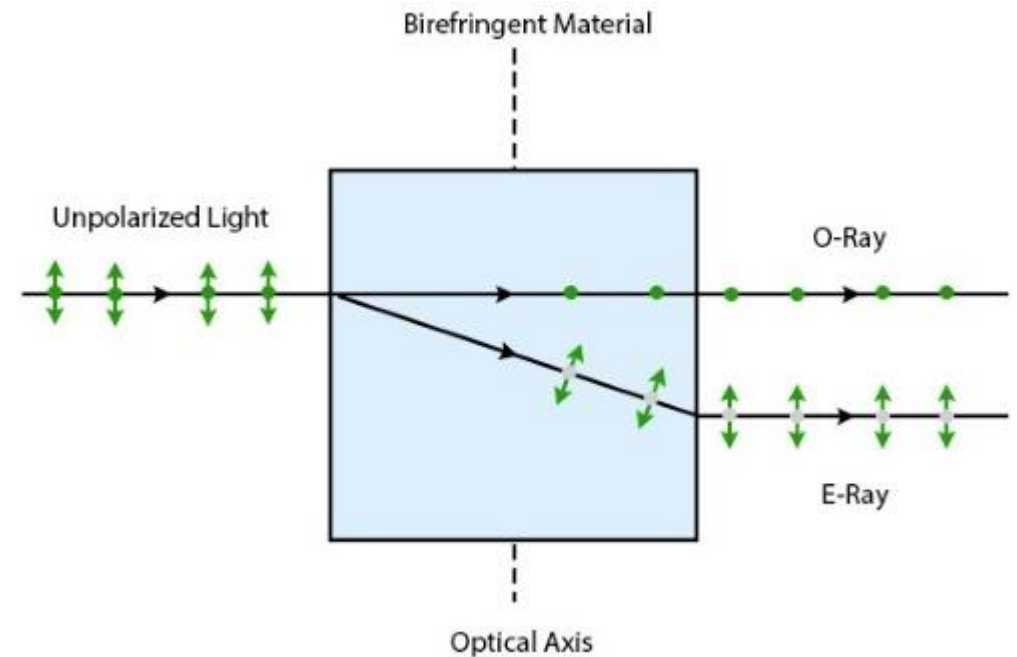


Fig.1. Scheme of Birefringence inside a birefringence material

Artificial birefringence

- One way to create an artificial birefringence is by creating a subwavelength grating on the materials.
- These structures are made by etching or ablating small grooves leaving as a result of air and material periodic sequence on a dielectric/ metal substrate.
- Materials like Silicon and Polymers such as HDPE and Teflon have small losses at THz frequencies which could make them a suitable material choice.
- Silicon gets a top pick in hand because of its high thermal stability, more transparent with minimal absorption losses, Low dispersion across the THz frequencies.

Table: Recent progress on THz waveplates

Materials classification			Bandwidth/ THz	Benefits	Drawbacks
Natural materials	Lithium niobate		~0.90	1. Large birefringence 2. Low dispersion	1. Brittle 2. High absorption 3. Complex fabrication process
	Quartz	Orthodox structure	~0.10	1. High transmittance 2. Low birefringence 3. Low dispersion	1. Low nonlinearity 2. High cost
		Special prism structure	~2.50		
	Artificial crystal		~0.20	1. Good transmittance 2. Stability 3. Low cost and easy fabrication	1. Higher refractive index 2. Weaker electrical and magnetic properties 3. High absorption rate 4. Poor thermal stability
Grating	Metal-based		~0.60	1. High phase modulation 2. High durability 3. Suitable for harsh environments	1. High absorption and reflection losses
	Dielectric-based		~0.40	2. Low loss 1. High phase modulation 2. High precision	1. More fragile than metal-based wave plates
Metamaterial	Metal-Insulator-Metal		~0.52	1. High transmission efficiency 2. Low insertion loss	1. Challenging to fabricate 2. High optical losses and absorption
	Dielectric		~0.25	1. High transmission efficiency 2. Low insertion loss 3. Good temperature stability	1. Limited bandwidth 2. Challenging to fabricate
	Hybrid Metal-Dielectric		~0.32	1. Broadband operation 2. High transmission efficiency 3. Low insertion loss.	1. Challenging to fabricate 2. High optical losses and absorption
	Chiral		~0.50	1. Broadband operation a 2. High transmission efficiency.	1. Challenging to fabricate 2. Limited polarization selectivity.

Design of Silicon grating

- Initially, monolayer-silicon-based grating was developed with a subwavelength periodic material-air interfaces with a period of $P = 100\mu\text{m}$ on top of a HRFZ-Si silicon wafer with a overall thickness of $t/2 = 250\mu\text{m}$. The grating height of a waveplate was kept at $h = 200\mu\text{m}$ i.e the height of ridge from the groove and the width of ridges was kept at w .

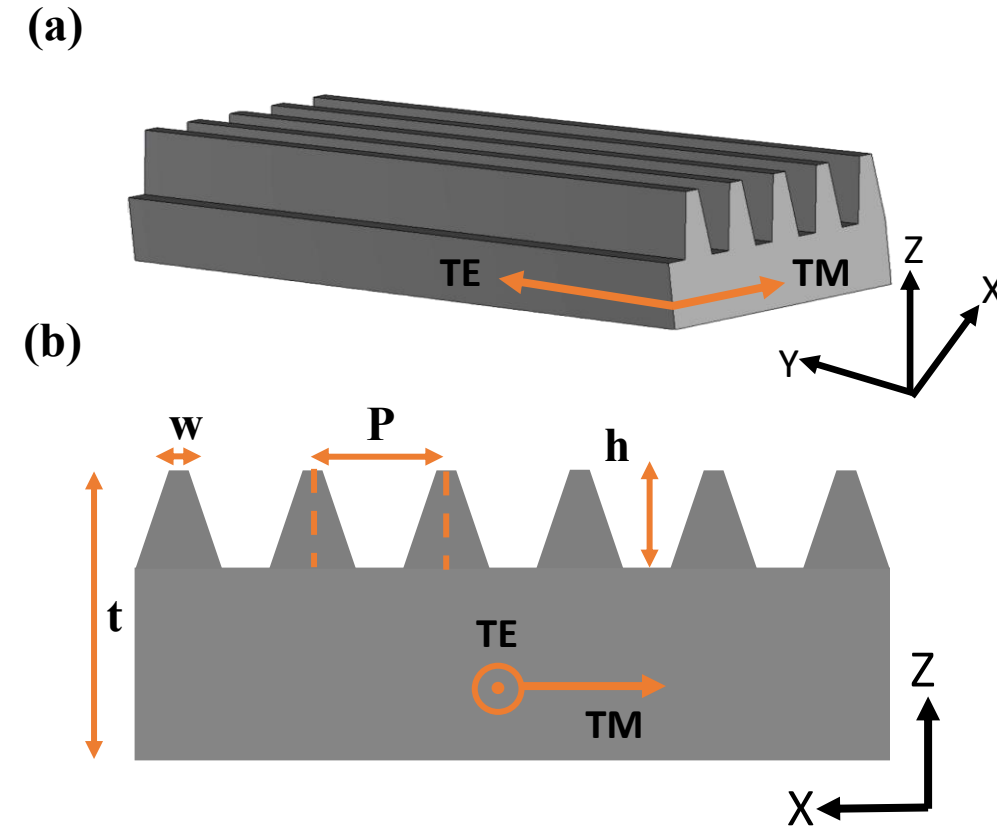


Fig.2. Schematic representation of monolayer-silicon-based grating; (a) 3D representation of a developed silicon grating (b) monolayer-silicon-based grating along XZ-axis with a design parameters.

Fabrication

- Material-Air Gratings were developed of high resistivity floating zone (HRFZ) silicon (Si) wafer employing the Direct Laser Ablation (DLA) technique.
- The DLA was used for fabrication of grating samples using a precisely focused laser beam to remove material from the substrate, enabling the creation of well-defined grooves and ridges.

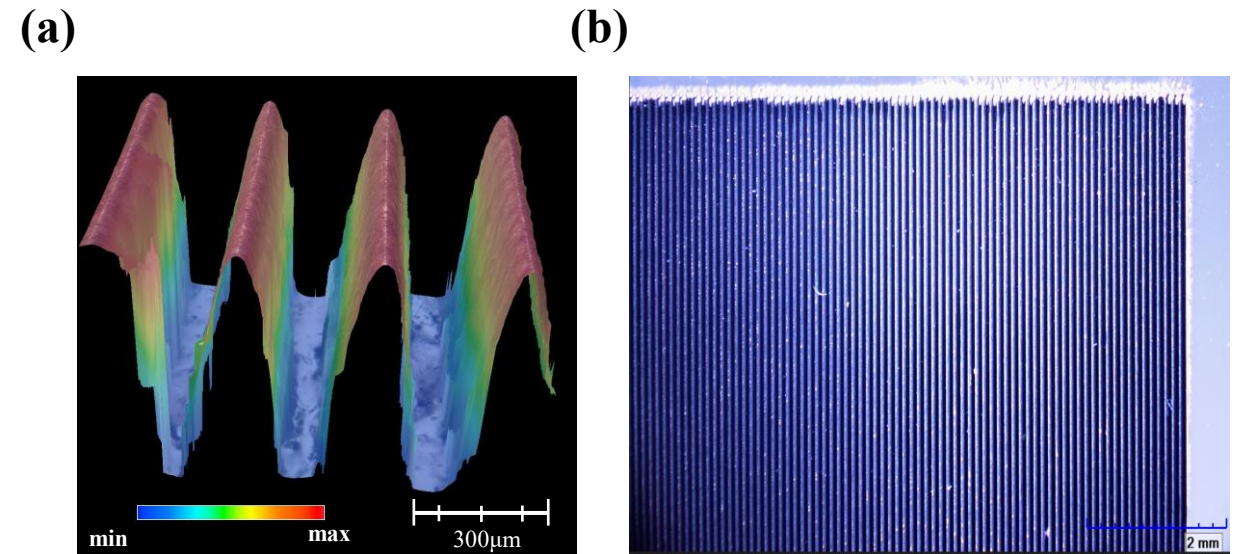


Fig.3. (a) Profile of a silicon grating was shown in colour scale along XZ-axis with a $h=200\mu\text{m}$ and period of $P=100\mu\text{m}$ taken from the optical profilometer, showing grating ridges (red colour) and grating grooves (blue colour), (b) Microscopic image of a waveplate along XY-axis.

Characterization

- The transmission results for both the TE and TM polarizations were compared between the FDTD Simulations, TDS and VNA measurements.
- Shows the phase retardation between TE and TM polarizations across the frequency where it achieves 90 ± 10 degrees of phase shift for a bandwidth of 200 GHz for a frequency of 0.3 to 0.5 THz and can work as a quarter waveplate (QWP).

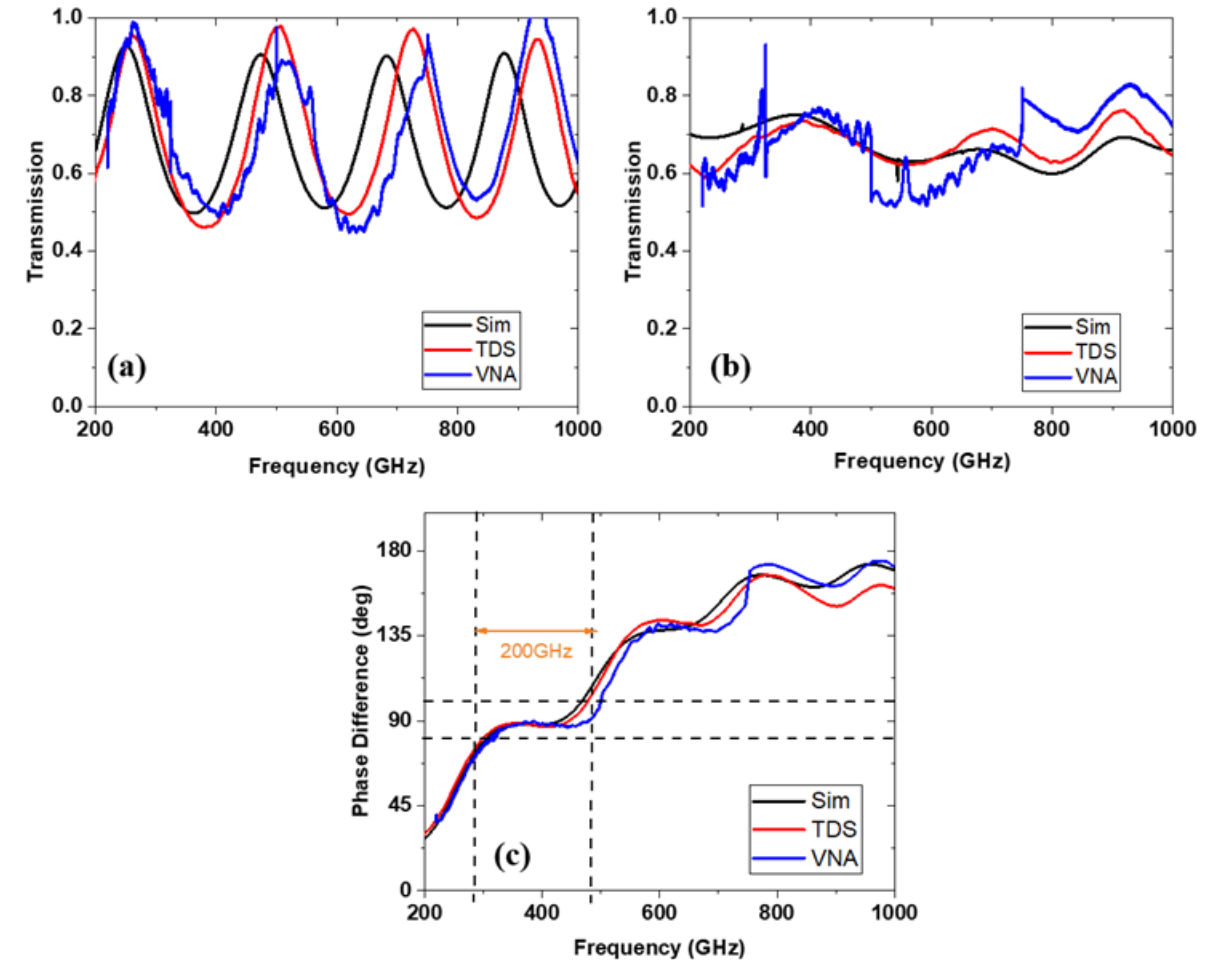


Fig.4. Transmission and Phase characteristics of a monolayer-silicon-based grating compared between FDTD simulations, THz-TDs setup and VNA setup, (a) along TE polarization (b) along TM polarization, and (c) Phase difference between TE and TM polarizations.

Polarization measurements:

- We conducted an experimental investigation to assess the polarization performance of a sample employing a THz Frequency Domain (THz-FDs) setup utilizing a Toptica Terascan 780 spectrometer.

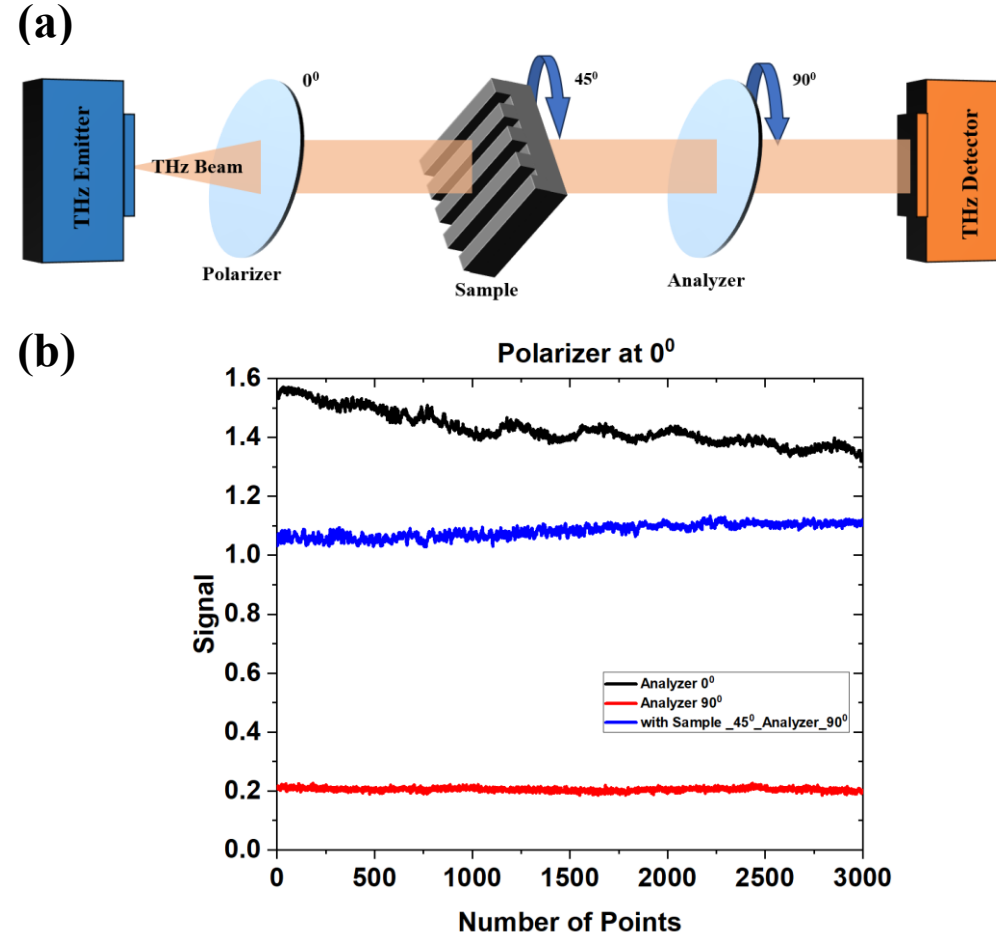


Fig.5. (a) Schematic representation of polarization measurement setup for a waveplate. (b) Measurement of different polarization states at fixed 400 GHz frequency with analyzer placed parallel (0°) to polarizer (black curve); with both crossed (90°) without (Red curve) and with the sample placed in between and oriented at 45 degrees (Blue curve).

Design of Double-sided Silicon grating

- To improve the transmission performance of a waveplate along the grating axis or TM polarization we've made a modification to the previously mentioned single-sided silicon grating waveplate transforming to double-sided silicon grating waveplate. [M. Tamosiunaite *et al.*, *IEEE Trans. Terahertz Sci. Technol.*, doi: 10.1109/TTHZ.2018.2859619]
- Period $P_T = P_B = 100\mu\text{m}$ and height of grating $h_T = h_B = 100\mu\text{m}$ on both top and bottom sides of a HRFZ-Si wafer with a overall thickness of $t = 500\mu\text{m}$.

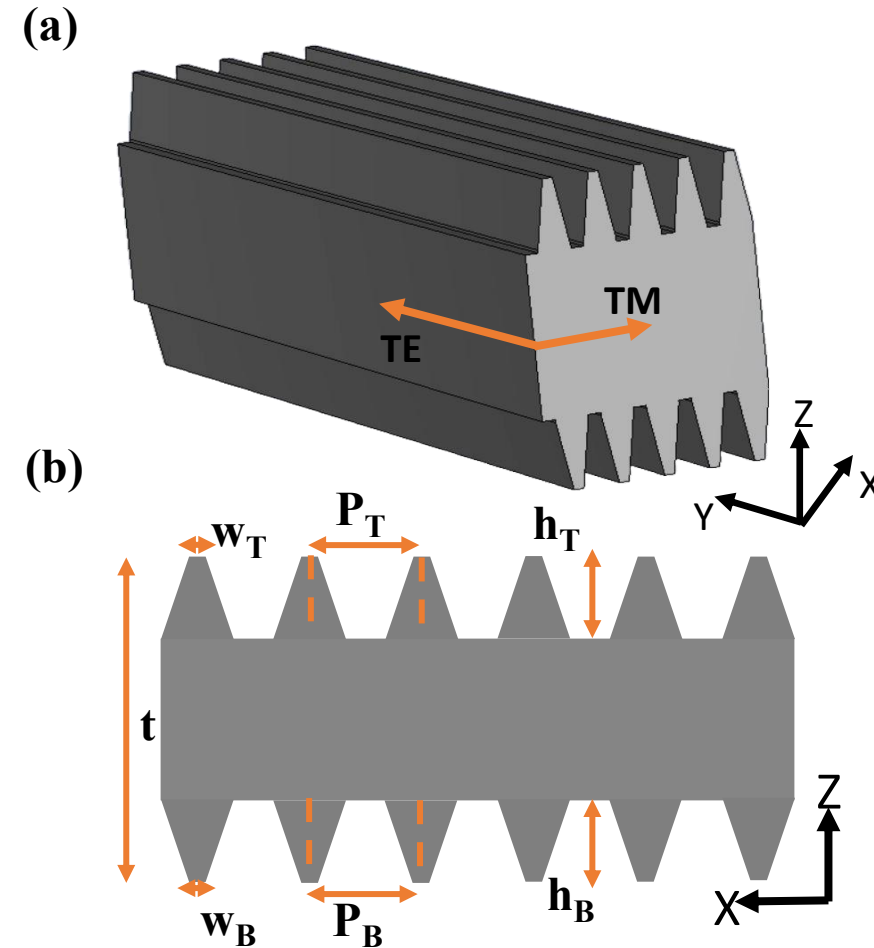


Fig.6. Schematic representation of double-sided silicon-based grating; (a) 3D representation of a developed silicon grating (b) double-sided silicon grating waveplate along XZ-axis with design parameters.

- Enhanced transmission performance is observed within the frequency range of 0.4 THz to 0.9 THz approaching nearly to 100% with a broadband operational bandwidth of 500 GHz for Simulation/Experimental findings for TM polarization.
- Conversely, we can achieve the required π phase shift between TE and TM polarizations, enabling the waveplate to function as a Half-Wave Plate (HWP) in the frequency range of 0.778 THz to 0.978 THz, with an operational bandwidth spanning 200 GHz for simulations.

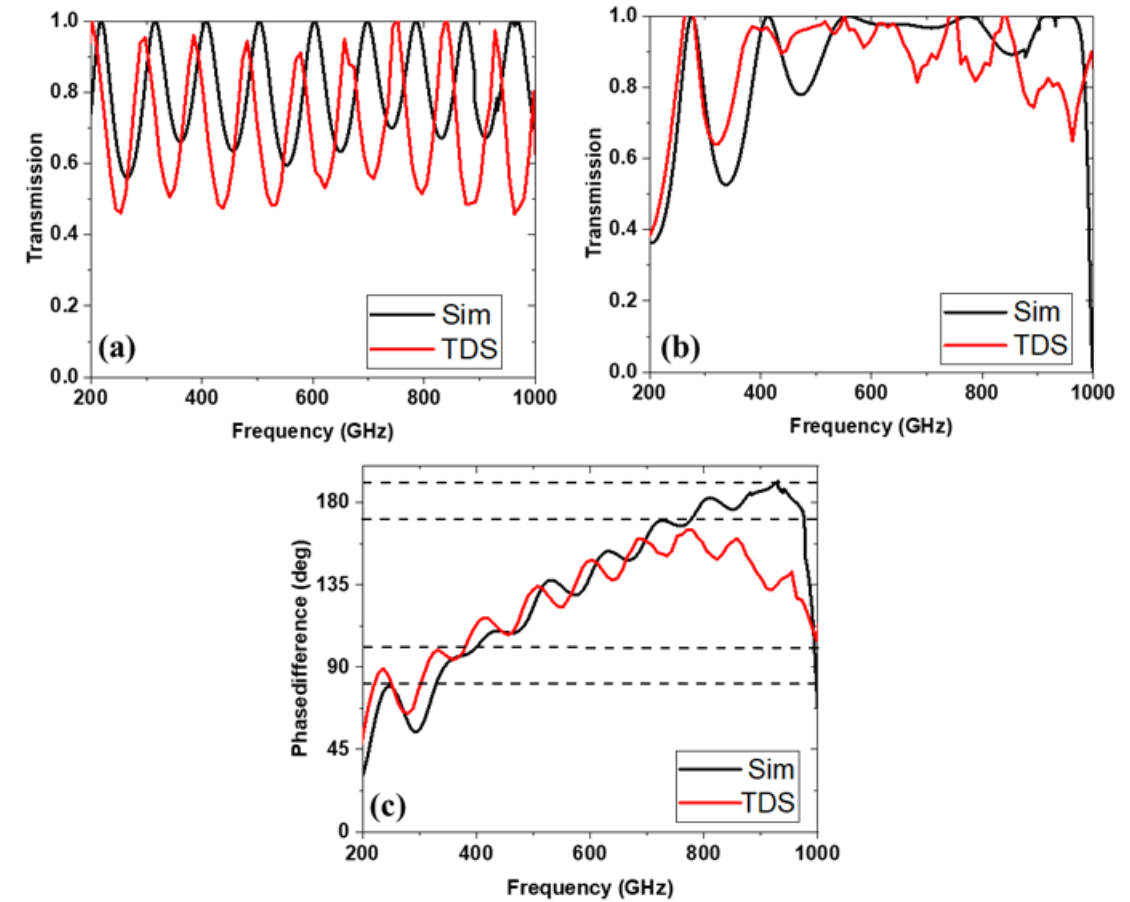


Fig.5. Double-sided dielectric-based grating waveplate (a) Transmission spectra of TM and TE polarizations for simulation (Black) and measurements (Red curve) (b) Phase measurements for simulation (Black) and measurements (Red curve).

Conclusions

- We developed a monolayer silicon grating waveplate based on artificial birefringence operating as a quarter waveplate (QWP) in the frequency range of 0.3 to 0.5 THz, with an operational bandwidth of 200 GHz is presented both theoretically and experimentally.
- Furthermore, by incorporating such similar grating structures on the bottom side of a sample helps us to improve the transmission performance of a waveplate reaching up to 100% for a broadband THz frequencies.
- The proposed waveplates possess anti-reflective behaviour along TM polarization due to inclination of grating walls allowing to suppress the reflection losses caused by Silicon-air interfaces.
- Such waveplates with high transmission and phase retardation immense promise for applications requiring precise polarization control and efficient terahertz wave transmission.

Acknowledgement

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